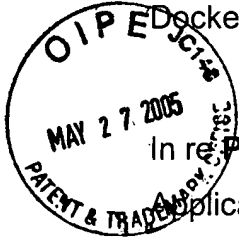


IFW



Docket No. AMDP798US

H1983

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: **PATENT** application of:

Applicant: Tazrien Kamal et al.

Application No.: 10/729,732

For: HARD MASK SPACER FOR SUBLITHOGRAPHIC BITLINE

Filing Date: December 5, 2003

Examiner: Evan T. Pert

Art Unit: 2826

REPLY TO OFFICE ACTION DATED MAY 12, 2005

Mail Stop Amendment
Assistant Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Favorable reconsideration of the above-identified application is respectfully requested in view of the following remarks.